

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Application of

Applicant : Gurtej S. Sandhu
Serial No. : 10/765,314
Filed : January 27, 2004
Title : ATOMIC LAYER DEPOSITION WITH POINT OF USE GENERATED
REACTIVE GAS SPECIES
Docket : MIO 0092 NA
Art Unit : 1762
Confirm. No. : 9407

EFS WEB ELECTRONIC SUBMISSION
October 26, 2007

MAIL STOP AMENDMENT
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

PRELIMINARY AMENDMENT

Please preliminarily amend this application to place it in better condition for examination. Consideration of the present application is respectfully requested in light of the amendments below, which include, in order of appearance, beginning on separate sheets:

- Amendments to the Claims; and
- Remarks.